

FILE. 1

ANODE SIDE	THICKNESS(nm)	CATHODE SIDE	THICKNESS(nm)
0 LAYER(LIGHT EMITTING LAYER)	0	0 LAYER(LIGHT EMITTING LAYER)	0
1st (HTL / HIL)	33	1st LAYER(ETL / EIL)	90
2nd(ITO)	110	2nd LAYER(Ag)	8
3rd(SSE-SIN) 4th(CAPACITIVE RESIN) 5th(SIN)	100	3rd LAYER(ITO)	260
6th(G)	1000	4th LAYER(SP-SIN)	100
7th(SIN)	100	5th LAYER(AIR)	0
GLASS SUBSTRATE	50	GLASS SUBSTRATE	



LAMINATED STRUCTURE

ANODE LAYER TFT\ITO\EL(HIL\HTL\EML)\EL(EML\ETL\EIL)\Ag\ITO\SP-SIN CATHODE LAYER

↑
LIGHT
EMITTING
LAYER

Fig. 2

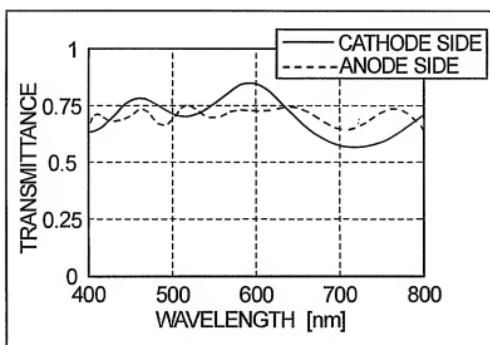


FIG. 3A

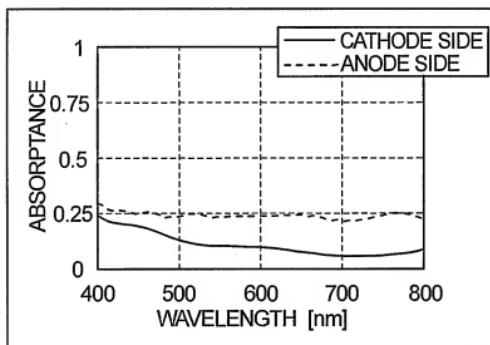


FIG. 3B

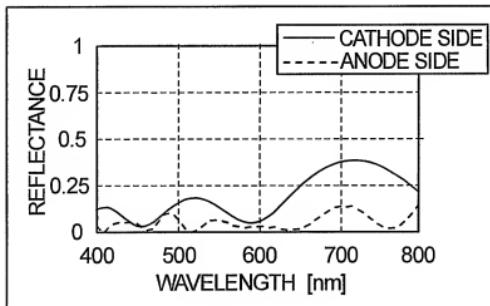


FIG. 3C

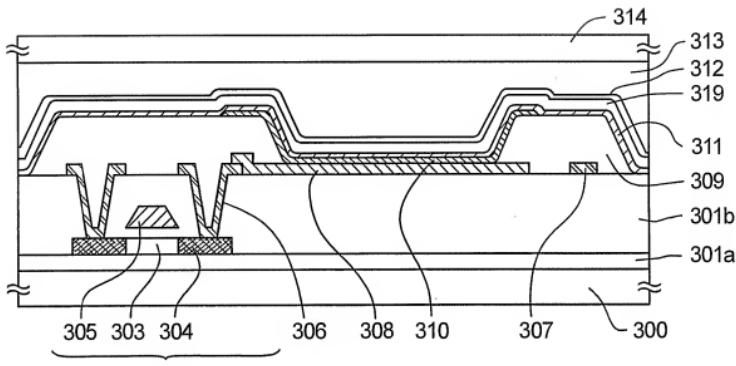


FIG. 4A

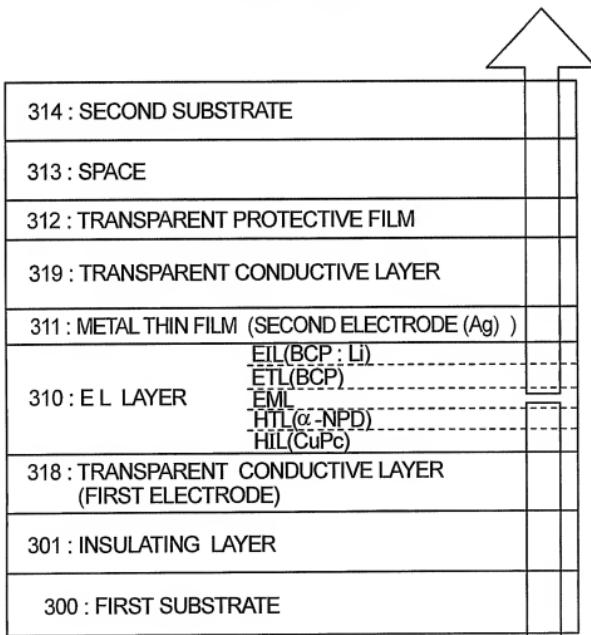


FIG. 4B

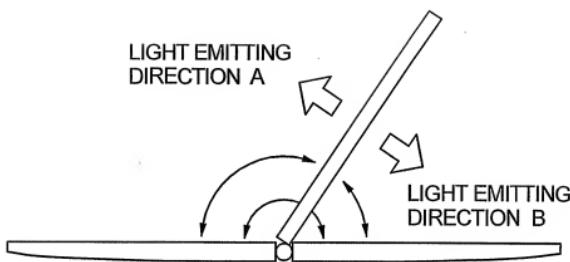


FIG. 5A

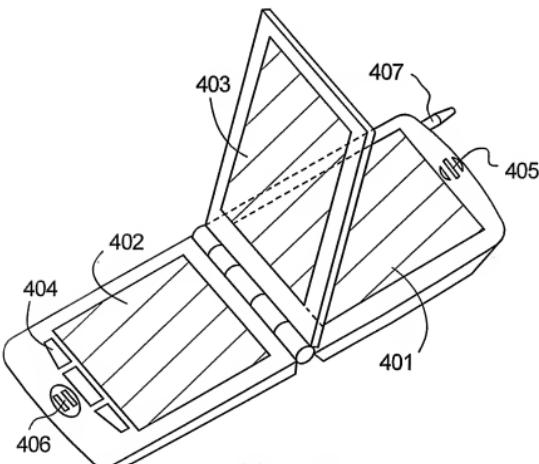


FIG. 5B

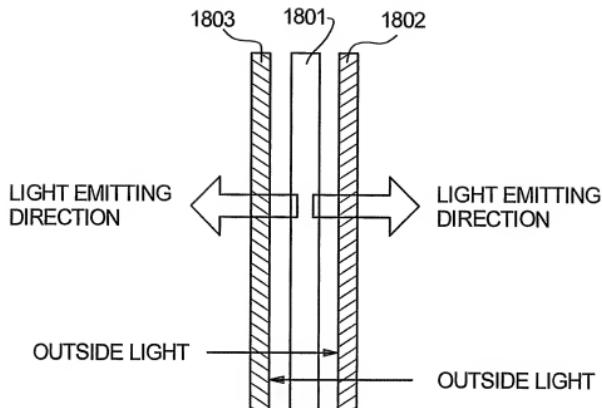


FIG. 6A

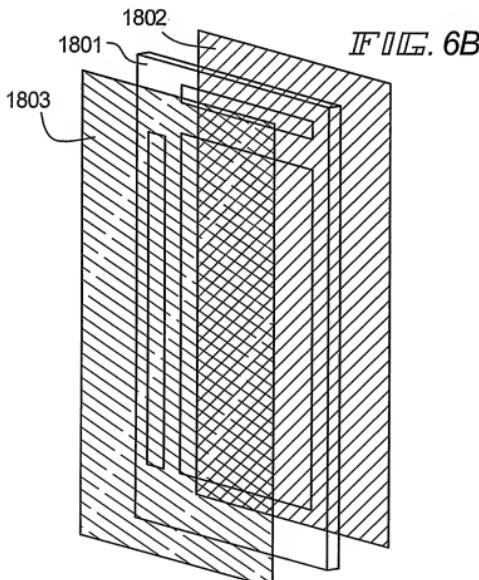
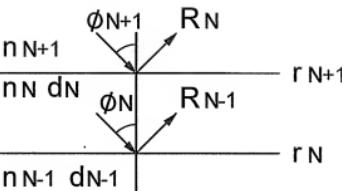
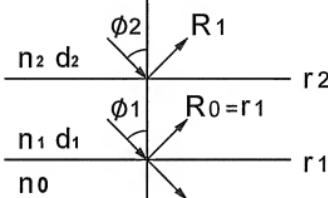


FIG. 6B



FIE. 7



FIE. 8

